

GEMOLOGICAL INSTITUTE

# **ELECTRONIC COPY**

## LABORATORY GROWN DIAMOND REPORT

December 18, 2024	
IGI Report Number	LG669415640
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	EMERALD CUT
Measurements	9.11 X 6.42 X 3.93 MM
GRADING RESULTS	
Carat Weight	2.55 CAPATS

	2.55 CARAIS	
Color Grade	FANCY VIVID PINK	
Clarity Grade	VS 1	

## ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	VERY GOOD
Fluorescence	SLIGHT
Inscription(s)	131 LG669415640

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Indications of post-growth treatment.

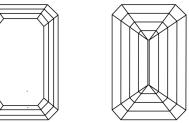
70% --Thick To 16.5% Very Thick  $\checkmark$ 61.2% 37% Long

LG669415640

Report verification at igi.org

## **CLARITY CHARACTERISTICS**

PROPORTIONS



#### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

151 LG669415640 Sample Image Used

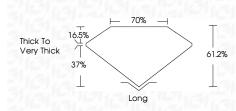
# COLOR

D E F	GHIJ	Faint	Very Light	Light
CLARITY	WVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	11-3
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

LABORATORY GROWN DIAMOND REPORT

# 

	December 10, 2024	
I	GI Report Number	LG669415640
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٢	Measurements	9.11 X 6.42 X 3.93 MM
(	GRADING RESULTS	
(	Carat Weight	2.55 CARATS
(	Color Grade	FANCY VIVID PINK
(	Clarity Grade	VS 1



#### ADDITIONAL GRADING INFORMATION

Symmetry VERY GOOD Fluorescence SLIGHT inscription(s) (G) LG669415640 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth		
Fluorescence SUGHT nscription(s) (G) LG669415640 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
nscription(s) (ACC) LG669415640 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	VERY GOOD
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	luorescence	SLIGHT
created by Chemical Vapor Deposition (CVD) growth process.	nscription(s)	低到 LG669415640
	created by Chemical Vapo process.	or Deposition (CVD) growth







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